



#10/3DS

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 1756  
Examiner: Kathleen Duda

In re PATENT APPLICATION of:

Applicant(s) : Minoru WATANABE )

Appln. No. : 10/025,783 )

Filed : December 26, 2001 )

For : METHOD AND APPARATUS FOR )  
FORMING RESIST PATTERN )

Atty. Dkt. : MAE 223 C1 )

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**INFORMATION  
DISCLOSURE  
STATEMENT**Commissioner for Patents  
Washington, D.C. 20231

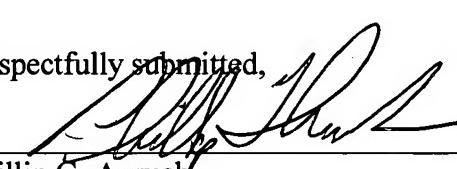
Sir:

This is an information disclosure statement submitted in compliance with the timing requirements of 37 C.F.R. §1.97(b)(1).

Attached are copies of four U.S. patent documents. The patents are listed on the attached Form PTO-1449.

Since this Information Disclosure Statement is being filed with the RCE application, no certification or fee is required, and the requirements of 37 C.F.R. §§1.97 and 1.98 are deemed to be fully met as to the document submitted. Consideration of the submitted document is respectfully requested.

Respectfully submitted,



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